# A comparative study of the thermal stability and reactions of $CH_2$ , $CH_3$ and $C_2H_5$ species on the Pd(100) surface

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Adsorbed CH<sub>2</sub>, CH<sub>3</sub> and C<sub>2</sub>H<sub>5</sub> moieties were produced on Pd(100) at 90 K by photoinduced dissociation of the corresponding iodo compounds, and their thermal reactions were established.

**Keywords**: adsorption of  $CH_3I$ ,  $C_2H_2I$  and  $C_2H_5I$ ; photo-induced formation of  $CH_3$ ,  $CH_2$  and  $C_2H_5$  species; decomposition and coupling of  $CH_x$  fragments on Pd(100)

### 1. Introduction

Hydrocarbon moieties,  $C_xH_y$ , are important reaction intermediates in the catalytic synthesis of hydrocarbons and in the transformation of  $CH_4$  into  $C_2H_6$  [1–3]. The study of their bonding and reactivity on catalysts is hampered by the fact that their reactions occur at relatively high temperatures, where the lifetime of the species  $C_xH_y$  on the catalyst surface is very limited. One possibility for the production of a fragment  $C_xH_y$  with a desired composition is the thermal dissociation of a corresponding halogenated hydrocarbon [4–9]. However, as demonstrated in previous papers [10–12], the complete dissociation of these compounds on Pd surfaces (even the least stable iodo compounds) requires an elevated temperature at which decomposition of the products proceeds in parallel with their formation. This problem can be circumvented by the photo-induced dissociation of the halogenated compounds at low temperature, following their adsorption on metal surfaces, a process which has been observed on the Pd(100) surface [10–12,14,15].

The aim of the present work is to produce CH<sub>2</sub>, CH<sub>3</sub> and C<sub>2</sub>H<sub>5</sub> moieties on the Pd(100) surface by photo-induced dissociation of the corresponding iodo com-

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pounds at 90 K, and to compare their thermal reactions by means of photoelectron (XPS and UPS) and thermal desorption (TPD) spectroscopy. It was recently found that methane molecules decompose (presumably through the formation of species  $CH_x$ ) at well-measurable rates on Pd single crystal on Pd(567) [16], and on supported Pd [17,18]. In the latter case, the formation of ethane was also reported. Supported Pd effectively catalysed the  $CH_4$ - $CO_2$  reaction too, to yield synthesis gas [19,20].

# 2. Experimental

The experiments were carried out in an ultrahigh vacuum system with a background pressure of  $5 \times 10^{-10}$  mbar. The system was equipped with an electrostatic hemispherical analyser (Leybold–Heraus LHS-10), a differentially pumped UV photon (He I, II) source for UPS, and Al K $\alpha$  X-ray for XPS. All binding energies are referred to the Fermi level with the Pd( $3d_{5/2}$ ) peak at 335.1 eV. The UV light source was a focussed 100 W Hg lamp. The light passed through a high-purity sapphire window into the vacuum chamber [10–12]. The oriented 4N9 purity, disk-shaped crystal was cleaned by cycles of argon ion bombardment, annealing (1000 K), oxygen treatment and short annealing (1100 K) [10–12]. All the compounds used were the products of Fluka. They were degassed and purified by freeze–pump–thaw cycles prior to use and stored in glass vials shielded from light to prevent photodecomposition.

## 3. Results and discussion

The easiest way to establish the dissociation of alkyl and alkenyl iodides on metal surfaces is via the binding energy (BE) of  $I(3d_{5/2})$ , as it differs by about 1.5–2.0 eV for molecularly adsorbed iodine compounds and for atomically adsorbed iodine. The intensity of the XPS peak for atomically adsorbed I is unaltered up to the temperature of desorption of I from Pd(100), 700–750 K [10–12].

## 3.1. THERMAL STABILITY AND REACTIONS OF ADSORBED CH<sub>3</sub>

The monolayer adsorption of  $CH_3I$  on Pd(100) caused a work function decrease of 1.54 eV.  $CH_3I$  adsorbed dissociatively at submonolayer coverages, and molecularly at high coverages. The adsorbed  $CH_3I$  monolayer is characterized by a BE of 620.5 eV for  $I(3d_{5/2})$  and 284.5 eV for C(1s) (fig. 1). As indicated by the BE for adsorbed I, complete dissociation was achieved by illumination for about 20 min. The occurrence of this process caused no shift in the BE for C(1s).

In the He II UPS, the species CH<sub>3</sub> formed in the photodissociation of CH<sub>3</sub>I at 90 K is characterized by a photoemission line at 8.5 eV [10] (fig. 2A). With increase of the temperature, the peak attenuated above 140–150 K and was detect-

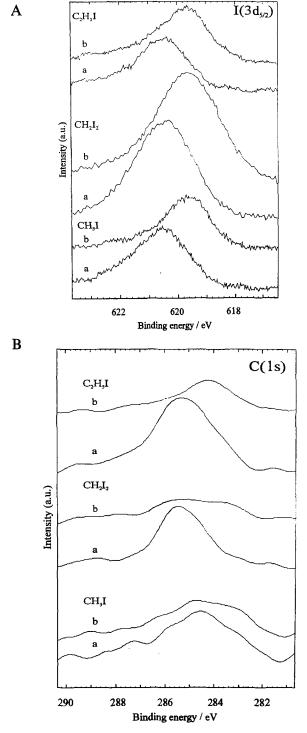


Fig. 1. XPS of  $I(3d_{5/2})$  (A) and C(1s) (B) of adsorbed  $CH_3I$ ,  $CH_2I_2$  and  $C_2H_5I$  (monolayer) before illumination (a) and after complete photo-induced dissociation (b).

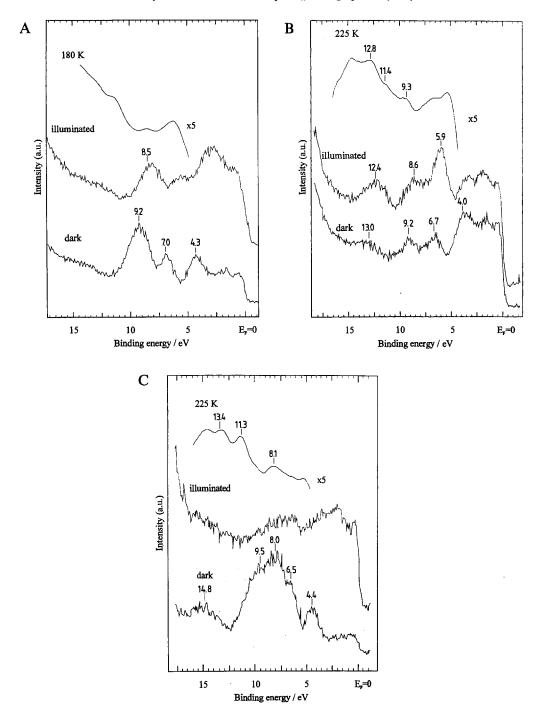


Fig. 2. He II UPS spectra of adsorbed CH<sub>3</sub>I (A), CH<sub>2</sub>I<sub>2</sub> (B) and C<sub>2</sub>H<sub>5</sub>I (C) at monolayer, after their complete photo-induced dissociation at 90 K and after subsequent heating. The uppermost spectra are difference spectra. In order to see clearly the characteristic signals of CH<sub>3</sub>I in UPS, its coverage was higher than monolayer.

able up to 250 K. There was no spectral indication of the transitory existence of the species CH<sub>2</sub> or CH, which means that if they were formed they decomposed further rapidly.

Post-irradiation TPD revealed that the main product of the decomposition of adsorbed CH<sub>3</sub> was methane ( $T_p = 170 \text{ K}$ ). Coupling of the CH<sub>3</sub> and that of CH<sub>2</sub> formed in its decomposition was very limited, as indicated by the small amount of ethane and ethylene desorbed ( $T_p = 175 \text{ K}$ ). The amount of C<sub>2</sub> compounds formed was only 3.5% of that of methane.

# 3.2. THERMAL STABILITY AND REACTIONS OF ADSORBED CH2

The monolayer adsorption of  $CH_2I_2$  results in a work function decrease of 0.85 eV. The adsorption was molecular at and above the monolayer, but the dissociation of  $CH_2I_2$  on Pd(100) occurred at low coverage. The BE values for  $I(3d_{5/2})$  and C(1s) at monolayer coverage were 620.4 and 285.5 eV, respectively (fig. 1). A shift in I BE occurred even at the shortest irradiation time,  $\sim 1$  min, but the BE value characteristic for atomically adsorbed I was reached only after irradiation for 5–7 min. In this case, the C(1s) peak was at 283.6 eV.

He II photoelectron spectra of the adsorbed layer after completion of the photo-induced dissociation of  $CH_2I_2$  are displayed in fig. 2B. The characteristic photoemission signal for adsorbed  $CH_2$  at low coverage was at 5.5 eV, which is in agreement with the value given for this species by Steinbach et al. [21]. When a monolayer of adsorbed  $CH_2I_2$  was illuminated for 5 min, all the signals characteristic of adsorbed  $CH_2I_2$  disappeared, an intense peak developed at 5.9 and weaker ones at 8.6 and 12.4 eV. As the positions of these photoemission lines approximated well to those observed following ethylene adsorption on Pt metals [16–18], we may conclude that a significant proportion of the  $CH_2(a)$  produced in the photo-induced dissociation process dimerized into adsorbed  $C_2H_4$  species even at 90 K. Annealing the adsorbed layer showed the characteristic features of di- $\sigma$ -bonded ethylene, which consists of the transient formations of both vinyl and ethylidyne [11].

In accord with this, post-irradiation TPD showed that the major product of the reactions of adsorbed  $CH_2$  at monolayer was ethylene, which desorbed in two peaks,  $T_p=230$  and 320 K. The formation of methane, indicative of self-hydrogenation of the species  $CH_2$ , also occurred ( $T_p=178-238$  K). The ratio  $C_2H_4/CH_4$  in the post-irradiation experiment was 3.0-3.5. These features are in harmony with the theoretical calculation, which showed that the activation energy of coupling of the species  $CH_2$  on metal surfaces is only 6-9 kcal/mol[22].

#### 3.3. THERMAL STABILITY AND REACTIONS OF ADSORBED C2H5

The work function decrease of the Pd(100) surface following the adsorption of  $C_2H_5I$  amounted to 2.00 eV. Independently of the coverage,  $C_2H_5I$  adsorbed molecularly on Pd(100) at 90 K. The  $I(3d_{5/2})$  and C(1s) binding energies for the

 $C_2H_5I$  monolayer were 620.4 and 285.2 eV (fig. 1). The C(1s) peak clearly consisted of two overlapping peaks at 285.7 and 285.0 eV: the higher value can be ascribed to the carbon directly bonded to the iodine. Complete dissociation of the  $C_2H_5I$  required illumination for 7 min. In this case the C(1s) signal was at 284.1 eV. On the assumption that the fragment  $C_2H_5$  produced in the photodissociation of  $C_2H_5I$  is stable at 90 K, we attribute this peak to the  $C_2H_5$  species. At the same time, photoemission lines appeared at 5.5–9.0 and 12.5 eV in the He II photoelectron spectra (fig. 2C). When the illuminated layer was heated, an observable change occurred at 169 K: the photoemission peaks moved to 6.2, 8.8 and 12.8 eV, which are nearly the same as observed for adsorbed ethylene. Further changes in the spectra correspond well to those observed during annealing of adsorbed ethylene.

Post-irradiation TPD indicated the formation of ethylene above 150 K ( $T_p = 190$  and 280 K) and also ethane ( $T_p = 180$  K). However, no methane or  $C_4$  compounds were detected in the desorbing products. Accordingly, the species  $C_2H_5$  started to dehydrogenate on the Pd(100) surface even above 150 K, to give adsorbed  $C_2H_4$ . This process was complete at around 200 K. A competitive reaction was the hydrogenation of  $C_2H_5$  moieties by the hydrogen in the background and by that produced in the dehydrogenation.

A dramatic change occurred in the reaction of  $C_2H_5$  species in the presence of Zn atoms produced by thermal- and photodissociation of  $(C_2H_5)_2$ Zn. In this case significant amounts of butene and butane were formed in addition to ethane and ethylene (fig. 3). We may assume that Zn adatoms, occupying the most active sites on Pd surface, inhibit its dehydrogenation effect on adsorbed CH<sub>3</sub>, thereby facilitating the coupling of  $C_xH_y$  fragments. Further studies on the effects of Zn adatoms are in progress in our laboratory.

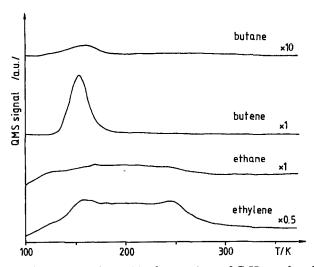


Fig. 3. TPD spectra for the products formed in the reactions of  $C_2H_5$  produced by illumination of adsorbed  $(C_2H_5)_2Zn$  (monolayer) at 90 K for 60 min.

### 4. Conclusions

(i) The species  $CH_3$  is stable on the Pd(100) surface up to 150 K, and undergoes self-hydrogenation at 150–250 K to yield methane. Its coupling to give ethane is very limited. (ii) The species  $CH_2$  is also self-hydrogenated to methane at 150–170 K, but, in contrast with  $CH_3$ , at high concentration it readily dimerizes to ethylene, even at 90 K. (iii)  $C_2H_5$  is stable up to 150–160 K. Above this temperature, both the dehydrogenation of  $C_2H_5$  to ethylene and its hydrogenation to ethane occur, without any sign of its coupling. However, the presence of Zn atoms greatly promoted the coupling reaction to butane and butene.

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